

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Yan, *et al.* Docket No.: 2003 P 51686 US
Serial No.: 10/615,630 Art Unit: 2825
Filed: July 9, 2003 Examiner: Calvin Lee
For: Method of Forming Shallow Trench Isolation Using Deep Trench Isolation

RECEIVED
CENTRAL FAX CENTER
SEP 18 2004

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Dear Sir:

The following amendments and remarks are presented in response to the Examiner's Office Action mailed June 18, 2004. Please amend the above-referenced application as follows.

2003 P 51686 US

Page 1 of 11

Amendment